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| INFORMATION DISCLOSURE CITATION (Use several sheets if necessary) | Docket Number (Optional) | Application Number |
| | 05426/014001 | 09/989,986 |
| | Applicant(s) Hideo TASHIRO et al. | |
| | Filing Date | Group Art Unit |
| | November 21, 2001 | 1645 |

U.S. PATENT DOCUMENTS

| EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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FOREIGN PATENT DOCUMENTS

| REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
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| EXAMINER | DATE CONSIDERED |
| R | 1/03 |

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.